

Douglas J Paul

List of Publications by Year in descending order

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291
papers

5,160
citations

101543
36
h-index

110387
64
g-index

294
all docs

294
docs citations

294
times ranked

5151
citing authors

#	ARTICLE	IF	CITATIONS
1	Ge-on-Si single-photon avalanche diode detectors for short-wave infrared wavelengths. <i>JPhys Photonics</i> , 2022, 4, 012001.	4.6	10
2	Silicon nitride waveguide polarization rotator and polarization beam splitter for chip-scale atomic systems. <i>APL Photonics</i> , 2022, 7, .	5.7	18
3	On-chip infrared photonics with Si-Ge-heterostructures: What is next?. <i>APL Photonics</i> , 2022, 7, .	5.7	18
4	A MEMS gravimeter with multi-axis gravitational sensitivity. , 2022, , .		2
5	A Simulation Study of the Temperature Sensitivity and Impact of Fabrication Tolerances on the Performance of a Geometric Anti-Spring Based MEMS Gravimeter. , 2022, , .		1
6	THz intersubband electroluminescence from n-type Ge/SiGe quantum cascade structures. <i>Applied Physics Letters</i> , 2021, 118, .	3.3	15
7	Terahertz intersubband electroluminescence from n-type germanium quantum wells. , 2021, , .		0
8	Field-resolved detection of the temporal response of a single plasmonic antenna in the mid-infrared. <i>Optica</i> , 2021, 8, 898.	9.3	14
9	Ge-on-Si Single-Photon Avalanche Diode Detectors with Low Noise Equivalent Power in the Short-Wave Infrared. , 2021, , .		0
10	Ge on Si Photonics Platform for Mid-Infrared Sensors. , 2021, , .		0
11	Faceting of Si and Ge crystals grown on deeply patterned Si substrates in the kinetic regime: phase-field modelling and experiments. <i>Scientific Reports</i> , 2021, 11, 18825.	3.3	4
12	Pseudo-planar Ge-on-Si single photon avalanche diode detector with record low noise-equivalent power. , 2021, , .		1
13	Current leakage mechanisms related to threading dislocations in Ge-rich SiGe heterostructures grown on Si(001). <i>Applied Physics Letters</i> , 2021, 119, .	3.3	3
14	THz Intersubband Emitter based on Silicon. , 2021, , .		0
15	Photonic Band Gap and Light Routing in Self-Assembled Lattices of Epitaxial $\text{Si}_{0.8}\text{Ge}_{0.2}$. xmlns:mml="http://www.w3.org/1998/Math/MathML" display="block"> $\text{Ge} \rightarrow \text{Si}_{0.8}\text{Ge}_{0.2}$ -on- $\text{Si}(001)$ Microstructures. <i>Physical Review Applied</i> , 2021, 16, .	3.8	1
16	Electron Population Dynamics in Optically Pumped Asymmetric Coupled Ge/SiGe Quantum Wells: Experiment and Models. <i>Photonics</i> , 2020, 7, 2.	2.0	5
17	Distributed Feedback Lasers for Quantum Cooling Applications. , 2020, , .		1
18	Self-Assembly of Nanovoids in Si Microcrystals Epitaxially Grown on Deeply Patterned Substrates. <i>Crystal Growth and Design</i> , 2020, 20, 2914-2920.	3.0	2

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19	Ultra-broadband mid-infrared Ge-on-Si waveguide polarization rotator. <i>APL Photonics</i> , 2020, 5, 026102.	5.7	21	
20	High efficiency planar geometry germanium-on-silicon single-photon avalanche diode detectors., , 2020, , .	5		
21	1.4 million Q factor Si ₃ N ₄ micro-ring resonator at 780nm wavelength for chip-scale atomic systems. <i>Optics Express</i> , 2020, 28, 4010.	3.4	18	
22	Terahertz absorption-saturation and emission from electron-doped germanium quantum wells. <i>Optics Express</i> , 2020, 28, 7245.	3.4	12	
23	Ge-on-Si waveguides for sensing in the molecular fingerprint regime. <i>Optics Express</i> , 2020, 28, 5749.	3.4	8	
24	3D LIDAR imaging using Ge-on-Si single-photon avalanche diode detectors. <i>Optics Express</i> , 2020, 28, 1330.	3.4	45	
25	Design and simulation of losses in Ge/SiGe terahertz quantum cascade laser waveguides. <i>Optics Express</i> , 2020, 28, 4786.	3.4	11	
26	Characterization of integrated waveguides by atomic-force-microscopy-assisted mid-infrared imaging and spectroscopy. <i>Optics Express</i> , 2020, 28, 22186.	3.4	9	
27	Sub-megahertz linewidth 780.24nm distributed feedback laser for ⁸⁷ Rb applications. <i>Optics Letters</i> , 2020, 45, 3529.	3.3	18	
28	High sensitivity Ge-on-Si single-photon avalanche diode detectors. <i>Optics Letters</i> , 2020, 45, 6406.	3.3	19	
29	1.4 Million Q-Factor 780 nm Wavelength Si3N4 Micro-rings for Chip-Scale Atomic Systems. , 2020, , .	3.3	1	
30	Ge-on-Si Waveguide Polarization Rotator Operating in the 8-14 Åm Atmospheric Transmission Window. , 2020, , .	0		
31	Ge-on-Si Single Photon Avalanche Diode Detectors for LIDAR in the Short Wave Infrared. , 2020, , .	0		
32	Field-resolved response of mid-infrared plasmonic antennas. , 2020, , .	0		
33	Narrow Linewidth Distributed Feedback Diode Lasers for Cooling in Cold Atom Systems. , 2020, , .	0		
34	Mid-infrared Sensing with Ge on Si Waveguides. , 2019, , .	0		
35	Thermal emissivity of silicon heterojunction solar cells. <i>Solar Energy Materials and Solar Cells</i> , 2019, 201, 110051.	6.2	9	
36	Geiger Mode Ge-on-Si Single-Photon Avalanche Diode Detectors. , 2019, , .	1		

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37	Towards a Mid-Infrared Lab-on-Chip Sensor using Ge-on-Si Waveguides., 2019, , .	0	
38	High-Q Si3N4 Ring Resonators for Locking 780nm GaAs-Based Distributed Feedback Laser. , 2019, , .	0	
39	Field-Resolved Response of Plasmonic Antennas. , 2019, , .	0	
40	Room temperature operation of <i>n</i> -type Ge/SiGe terahertz quantum cascade lasers predicted by non-equilibrium Green's functions. <i>Applied Physics Letters</i> , 2019, 114, .	3.3	45
41	High performance planar germanium-on-silicon single-photon avalanche diode detectors. <i>Nature Communications</i> , 2019, 10, 1086.	12.8	104
42	Ge-On-Si High Efficiency Spads at 1310 Nm., 2019, , .	1	
43	Understanding the Sidewall Dependence of Loss for Ge-on-Si Waveguides in the Mid-Infrared. , 2019, , .	0	
44	Geiger Mode Ge-on-Si Single-Photon Avalanche Diode Detectors. , 2019, , .	2	
45	n-type Ge/SiGe Multi Quantum-Wells for a THz Quantum Cascade Laser. <i>ECS Transactions</i> , 2019, 93, 63-66.	0.5	0
46	Electron-doped SiGe Quantum Well Terahertz Emitters pumped by FEL pulses. , 2019, , .	0	
47	N-Type Ge/SiGe Quantum Cascade Heterostructures for THz Emission. , 2019, , .	1	
48	Si-based n-type THz Quantum Cascade Emitter. , 2019, , .	0	
49	Strain analysis of a Ge micro disk using precession electron diffraction. <i>Journal of Applied Physics</i> , 2019, 126, .	2.5	10
50	Ultra Broadband Mid-Infrared Ge-on-Sipolarization Rotator. , 2019, , .	0	
51	Understanding the Sidewall Dependence of Loss for Ge-on-Si Waveguides in the Mid-Infrared. , 2019, , .	0	
52	Molecular Fingerprint Sensing using Ge-on-Si Waveguides. , 2019, , .	0	
53	Geiger Mode Ge-on-Si Single-Photon Avalanche Diode Detectors. , 2019, , .	3	
54	High-Quality n-Type Ge/SiGe Multilayers for THz Quantum Cascade Lasers. , 2019, , .	0	

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55	Control of Electron-State Coupling in Asymmetric $\langle mml:math \text{ xmlns:mml="http://www.w3.org/1998/Math/MathML" display="block">\frac{\partial^2 E}{\partial k_x^2} = \frac{2m}{\hbar^2} \left(\frac{1}{L_x} \right)^2 \left(\frac{1}{2} \left(\frac{E}{\hbar^2} + \frac{eV}{L_x} \right) \right)^2 - \frac{2m}{\hbar^2} \left(\frac{1}{L_x} \right)^2 \left(\frac{1}{2} \left(\frac{E}{\hbar^2} + \frac{eV}{L_x} \right) \right) \frac{\partial^2 E}{\partial k_y^2} \right)$ Quantum Wells. <i>Physical Review Applied</i> , 2019, 11, .	3.8	25
56	Low loss germanium-on-silicon waveguides for integrated mid-infrared photonics., 2019, ,.		3
57	Fingerprint mid-infrared sensing with germanium on silicon waveguides., 2019, ,.		1
58	Integrated DFB Lasers on Si3N4 Photonic Platform for Chip-Scale Atomic Systems., 2019, ,.		5
59	Field-Resolved Detection of the Temporal Response of a Mid-Infrared Plasmonic Antenna., 2019, ,.		0
60	High-efficiency Ge-on-Si SPADs for short-wave infrared., 2019, ,.		4
61	Ultra Broadband Mid-Infrared Ge-on-Si Polarization Rotator., 2019, ,.		0
62	Molecular Fingerprint Sensing using Ge-on-Si Waveguides., 2019, ,.		0
63	Microelectromechanical system gravimeters as a new tool for gravity imaging. <i>Philosophical Transactions Series A, Mathematical, Physical, and Engineering Sciences</i> , 2018, 376, 20170291.	3.4	11
64	Impact of Randomly Distributed Dopants on \$Omega\$ -Gate Junctionless Silicon Nanowire Transistors. <i>IEEE Transactions on Electron Devices</i> , 2018, 65, 1692-1698.	3.0	7
65	Topotactic anion-exchange in thermoelectric nanostructured layered tin chalcogenides with reduced selenium content. <i>Chemical Science</i> , 2018, 9, 3828-3836.	7.4	28
66	Interfacial sharpness and intermixing in a Ge-SiGe multiple quantum well structure. <i>Journal of Applied Physics</i> , 2018, 123, .	2.5	16
67	A High Stability Optical Shadow Sensor With Applications for Precision Accelerometers. <i>IEEE Sensors Journal</i> , 2018, 18, 4108-4116.	4.7	14
68	Mid-infrared emissivity of crystalline silicon solar cells. <i>Solar Energy Materials and Solar Cells</i> , 2018, 174, 607-615.	6.2	68
69	A Portable MEMS Gravimeter for the Detection of the Earth Tides., 2018, ,.		8
70	Components for Integrated Ge on Si for Mid-Infrared Photonic Sensors., 2018, ,.		0
71	Distributed Feedback Lasers Operating at 780 nm Wavelength Integrated on Si Substrates for Chip-scale Atomic Systems., 2018, ,.		1
72	Ge-on-Si Mid-Infrared Waveguides Operating up to 11 μ m Wavelength., 2018, ,.		0

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73	Quantum interference in silicon one-dimensional junctionless nanowire field-effect transistors. Physical Review B, 2018, 98, .	3.2	5
74	Plasmonic mid-infrared third harmonic generation in germanium nanoantennas. Light: Science and Applications, 2018, 7, 106.	16.6	42
75	Roadmap for the next-generation of hybrid photovoltaic-thermal solar energy collectors. Solar Energy, 2018, 174, 386-398.	6.1	77
76	Benchmarking the Use of Heavily Doped Ge for Plasmonics and Sensing in the Mid-Infrared. ACS Photonics, 2018, 5, 3601-3607.	6.6	31
77	Low loss Ge-on-Si waveguides operating in the 8–14 Åm atmospheric transmission window. Optics Express, 2018, 26, 25667.	3.4	56
78	Analysis of terahertz-emitting SiGe quantum cascade structures by transmission electron microscopy. , 2018, , 155-158.	0	
79	Advanced TEM analysis of strain-balanced Si/SiGe resonant tunnelling diode structures. , 2018, , 163-166.	0	
80	Chlorine-Enabled Electron Doping in Solution-Synthesized SnSe Thermoelectric Nanomaterials. Advanced Energy Materials, 2017, 7, 1602328.	19.5	64
81	Experimental and Simulation Study of Silicon Nanowire Transistors Using Heavily Doped Channels. IEEE Nanotechnology Magazine, 2017, 16, 727-735.	2.0	17
82	One dimensional transport in silicon nanowire junction-less field effect transistors. Scientific Reports, 2017, 7, 3004.	3.3	31
83	Optical properties of highly n-doped germanium obtained by <i>in situ</i> doping and laser annealing. Journal Physics D: Applied Physics, 2017, 50, 465103.	2.8	28
84	Germanium-on-silicon waveguides for mid-infrared photonic sensing chips. , 2017, , .	0	
85	Comparative Study of Annealed and High Temperature Grown ITO and AZO Films for Solar Energy Applications. MRS Advances, 2017, 2, 3117-3122.	0.9	1
86	ITO and AZO films for low emissivity coatings in hybrid photovoltaic-thermal applications. Solar Energy, 2017, 155, 82-92.	6.1	51
87	Integrated germanium-on-silicon waveguides for mid-infrared photonic sensing chips. , 2017, , .	1	
88	Mid-infrared n-Ge on Si plasmonic based microbolometer sensors. , 2017, , .	3	
89	Heavily-doped germanium on silicon with activated doping exceeding 1020 cm ⁻³ as an alternative to gold for mid-infrared plasmonics. , 2017, , .	0	
90	Tensile strained GeSn mid-infrared light emitters. , 2017, , .	0	

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91	n-Ge on Si for mid-infrared plasmonic sensors. , 2017,,.	5	
92	Mid-infrared light emission > 3 Åµm wavelength from tensile strained GeSn microdisks. Optics Express, 2017, 25, 25374.	3.4	34
93	Field Tests of a Portable MEMS Gravimeter. Sensors, 2017, 17, 2571.	3.8	28
94	GaAs-based distributed feedback laser at 780 nm for 87Rb cold atom quantum technology. , 2017,,.	4	
95	Germanium nanoantennas for plasmon-enhanced third harmonic generation in the mid infrared. , 2017, . .	0	
96	Variability study of high current junctionless silicon nanowire transistors. , 2017,,.	2	
97	Improved Light Incoupling in Planar Solar Cells via Improved Texture Morphology of PDMS Scattering Layer. , 2017,,.	2	
98	Mid-Infrared Third-Harmonic Emission from Heavily-Doped Germanium Plasmonic Nanoantennas. , 2017, . .	0	
99	Facile Surfactant-Free Synthesis of pâ€T Type SnSe Nanoplates with Exceptional Thermoelectric Power Factors. Angewandte Chemie, 2016, 128, 6543-6547.	2.0	9
100	Facile Surfactant-Free Synthesis of pâ€T Type SnSe Nanoplates with Exceptional Thermoelectric Power Factors. Angewandte Chemie - International Edition, 2016, 55, 6433-6437.	13.8	81
101	Scalable solar thermoelectrics and photovoltaics (SUNTRAP). AIP Conference Proceedings, 2016,,.	0.4	5
102	8-band kÅ·p modelling of mid-infrared intersubband absorption in Ge quantum wells. Journal of Applied Physics, 2016, 120, .	2.5	15
103	(Invited) The Use of Silicon-Germanium Superlattices in Thermoelectric Devices and Microfabricated Generators. ECS Transactions, 2016, 75, 469-478.	0.5	1
104	Ge-on-Si Photonics for Mid-infrared Sensing Applications. MRS Advances, 2016, 1, 3269-3279.	0.9	0
105	Disentangling nonradiative recombination processes in Ge micro-crystals on Si substrates. Applied Physics Letters, 2016, 108, .	3.3	14
106	Experimental and simulation study of a high current 1D silicon nanowire transistor using heavily doped channels. , 2016,,.	1	
107	Specially designed solar cells for hybrid photovoltaic-thermal generators. , 2016,,.	3	
108	Mid-infrared intersubband absorption from p-Ge quantum wells on Si. , 2016,,.	0	

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109	Germanium plasmonic nanoantennas for third-harmonic generation in the mid infrared. , 2016, , .	2	
110	Benchmarking the use of heavily-doped Ge against noble metals for plasmonics and sensing in the mid-infrared. , 2016, , .	0	
111	Mid-infrared plasmonic platform based on n-doped Ge-on-Si: Molecular sensing with germanium nano-antennas on Si. , 2016, , .	1	
112	Mid-infrared intersubband absorption from p-Ge quantum wells grown on Si substrates. Applied Physics Letters, 2016, 108, .	3.3	22
113	Measurement of the Earth tides with a MEMS gravimeter. Nature, 2016, 531, 614-617.	27.8	237
114	Engineering Large In-Plane Tensile Strains in Ge Microdisks, Microrings and Racetrack Optical Cavities. ECS Transactions, 2016, 75, 633-640.	0.5	0
115	Analysis of Ge micro-cavities with in-plane tensile strains above 2 %. Optics Express, 2016, 24, 4365.	3.4	38
116	Tunability of the dielectric function of heavily doped germanium thin films for mid-infrared plasmonics. Physical Review B, 2016, 94, .	3.2	86
117	Optical Activation of Germanium Plasmonic Antennas in the Mid-Infrared. Physical Review Letters, 2016, 117, 047401.	7.8	55
118	Mid-Infrared Sensing Using Heavily Doped Germanium Plasmonics on Silicon Substrates. ECS Transactions, 2016, 75, 247-251.	0.5	0
119	Mid-Infrared Intersubband Absorption from p-Ge Quantum Wells Grown on Si Substrates. ECS Transactions, 2016, 75, 253-256.	0.5	0
120	Intersubband absorption in p-Ge QWs on Si. , 2016, , .	0	
121	Expanding the Ge emission wavelength to $2.25 \frac{1}{4}m$ with SixNy strain engineering. Thin Solid Films, 2016, 602, 60-63.	1.8	3
122	Ba ₆ ~ ₃ x Nd ₈ + ₂ x Ti ₁₈ O ₅₄ Tungsten Bronze: A New High-Temperature n-Type Oxide Thermoelectric. Journal of Electronic Materials, 2016, 45, 1894-1899.	2.2	17
123	The UK National Quantum Technologies Hub in sensors and metrology (Keynote Paper). Proceedings of SPIE, 2016, , .	0.8	10
124	A novel absorptive/reflective solar concentrator for heat and electricity generation: An optical and thermal analysis. Energy Conversion and Management, 2016, 114, 142-153.	9.2	23
125	Fabrication of mid-infrared plasmonic antennas based on heavily doped germanium thin films. Thin Solid Films, 2016, 602, 52-55.	1.8	8
126	Thermoelectric cross-plane properties on p- and n-Ge/SixGe _{1-x} superlattices. Thin Solid Films, 2016, 602, 90-94.	1.8	4

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127	Chapter 4. Nano- and Micro-fabrication Techniques for Improving Thermoelectric Materials and Generators. RSC Energy and Environment Series, 2016, , 83-108.	0.5	1
128	Engineering Large In-Plane Tensile Strains in Ge Microdisks, Microrings and Racetrack Optical Cavities. ECS Meeting Abstracts, 2016, , .	0.0	0
129	Mid-Infrared Intersubband Absorption from p-Ge Quantum Wells Grown on Si Substrates. ECS Meeting Abstracts, 2016, , .	0.0	0
130	(Invited) The Use of Silicon-Germanium Superlattices in Thermoelectric Devices and Microfabricated Generators. ECS Meeting Abstracts, 2016, , .	0.0	0
131	Mid-Infrared Sensing Using Heavily Doped Germanium Plasmonics on Silicon Substrates. ECS Meeting Abstracts, 2016, , .	0.0	0
132	Heavily phosphorous-doped Germanium thin films for mid-infrared plasmonics. , 2015, , .	0	
133	Highly strained Ge on Si microdisks with silicon nitride stressors. , 2015, , .	0	
134	Group-IV midinfrared plasmonics. Journal of Nanophotonics, 2015, 9, 093789.	1.0	27
135	Modelling and experimental verification of a Ge/SiGe thermoelectric generator. , 2015, , .	3	
136	Time- and frequency-resolved electrodynamics of germanium nanoantennas for mid-infrared plasmonics. , 2015, , .	0	
137	Optical Switching of Mid-Infrared Plasmonic Nanoantennas Based on Germanium. , 2015, , .	0	
138	Multiphysics Simulations of a Thermoelectric Generator. Energy Procedia, 2015, 75, 633-638.	1.8	21
139	Mid-infrared intersubband absorption in p-Ge/SiGe quantum wells grown on Si. , 2015, , .	0	
140	Finite Element Modelling To Evaluate the Cross-plane Thermal conductivity and Seebeck Coefficient of Ge/SiGe Heterostructure. Materials Today: Proceedings, 2015, 2, 510-518.	1.8	2
141	Mid-infrared plasmonic resonances exploiting heavily-doped Ge on Si. Proceedings of SPIE, 2015, , .	0.8	1
142	Extending the emission wavelength of Ge nanopillars to $225 \frac{1}{4}m$ using silicon nitride stressors. Optics Express, 2015, 23, 18193.	3.4	25
143	Midinfrared Plasmon-Enhanced Spectroscopy with Germanium Antennas on Silicon Substrates. Nano Letters, 2015, 15, 7225-7231.	9.1	173
144	Coupled Simulation of Performance of a Crossed Compound Parabolic Concentrator with Solar Cell. Energy Procedia, 2015, 75, 325-330.	1.8	10

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145	Principles and Applications of THz Time Domain Spectroscopy. Springer Series in Optical Sciences, 2014, , 203-231.	0.7	9
146	Terahertz Frequency Security Systems and Terahertz Safety Considerations. Springer Series in Optical Sciences, 2014, , 233-255.	0.7	3
147	Mid-infrared plasmonic germanium antennas on silicon. , 2014, , .	1	
148	Process induced tensile strain of Ge on Si nanopillars by ICP-PECVD SiN stressor layers. , 2014, , .	0	
149	Mid-infrared plasmonic platform based on heavily doped epitaxial Ge-on-Si: Retrieving the optical constants of thin Ge epilayers. , 2014, , .	5	
150	Ge/SiGe quantum confined Stark effect electro-absorption modulation with low voltage swing at $\lambda = 1550$ nm. Optics Express, 2014, 22, 19284.	3.4	25
151	Ge/SiGe quantum confined Stark effect modulators with low voltage swing at $\lambda = 1550$ nm. , 2014, , .	0	
152	Silver antimony Ohmic contacts to moderately doped n-type germanium. Applied Physics Letters, 2014, 104, .	3.3	9
153	(Invited) The Thermoelectric Properties of Ge/SiGe Based Superlattices: from Materials to Energy Harvesting Modules. ECS Transactions, 2014, 64, 929-937.	0.5	1
154	Physics and Applications of Terahertz Radiation. Springer Series in Optical Sciences, 2014, , .	0.7	66
155	Quantum Well Photodetectors. Springer Series in Optical Sciences, 2014, , 3-34.	0.7	1
156	Beyond Moore's law. Philosophical Transactions Series A, Mathematical, Physical, and Engineering Sciences, 2014, 372, 20130376.	3.4	9
157	Design and fabrication of memory devices based on nanoscale polyoxometalate clusters. Nature, 2014, 515, 545-549.	27.8	301
158	Thin SiGe virtual substrates for Ge heterostructures integration on silicon. Journal of Applied Physics, 2014, 115, .	2.5	28
159	Determining the Electronic Performance Limitations in Top-Down-Fabricated Si Nanowires with Mean Widths Down to 4 nm. Nano Letters, 2014, 14, 6056-6060.	9.1	25
160	Multilayered Ge/SiGe Material in Microfabricated Thermoelectric Modules. Journal of Electronic Materials, 2014, 43, 3838-3843.	2.2	5
161	Prospects for SiGe thermoelectric generators. Solid-State Electronics, 2014, 98, 70-74.	1.4	21
162	THz Bolometer Detectors. Springer Series in Optical Sciences, 2014, , 35-75.	0.7	11

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163	Relativistic Electrons-Based THz Sources: Principles of Operation and the ENEA Experience. Springer Series in Optical Sciences, 2014, , 123-148.	0.7	1
164	Physics and Applications of T-Rays. Springer Series in Optical Sciences, 2014, , 149-175.	0.7	2
165	Terahertz Control. Springer Series in Optical Sciences, 2014, , 179-202.	0.7	0
166	Terahertz Plasma Field Effect Transistors. Springer Series in Optical Sciences, 2014, , 77-100.	0.7	4
167	Thermal Conductivity Measurement Methods for SiGe Thermoelectric Materials. Journal of Electronic Materials, 2013, 42, 2376-2380.	2.2	9
168	Ge/SiGe Superlattices for Thermoelectric Devices Grown by Low-Energy Plasma-Enhanced Chemical Vapor Deposition. Journal of Electronic Materials, 2013, 42, 2030-2034.	2.2	10
169	Power Factor Characterization of Ge/SiGe Thermoelectric Superlattices at 300ÅK. Journal of Electronic Materials, 2013, 42, 1449-1453.	2.2	7
170	Ge/SiGe superlattices for nanostructured thermoelectric modules. Thin Solid Films, 2013, 543, 153-156.	1.8	16
171	Prospects for SiGe thermoelectric generators. , 2013, , .		1
172	Strained germanium nanostructures on silicon emitting at >2.2 µm wavelength. , 2013, , .		5
173	The cross-plane thermoelectric properties of p-Ge/Si0.5Ge0.5 superlattices. Applied Physics Letters, 2013, 103, .	3.3	47
174	Design and performance of a prototype mesa-geometry Ge-on-Si single-photon avalanche diode detector at 1310 nm and 1550 nm wavelengths. , 2013, , .		0
175	Ge/SiGe superlattices for thermoelectric energy conversion devices. Journal of Materials Science, 2013, 48, 2829-2835.	3.7	23
176	The thermoelectric properties of Ge/SiGe modulation doped superlattices. Journal of Applied Physics, 2013, 113, .	2.5	65
177	Ge-on-Si Single-Photon Avalanche Diode Detectors: Design, Modeling, Fabrication, and Characterization at Wavelengths 1310 and 1550 nm. IEEE Transactions on Electron Devices, 2013, 60, 3807-3813.	3.0	116
178	Low Specific Ohmic Contacts to n-type Germanium Using a Low Temperature NiGe Process. ECS Transactions, 2013, 50, 1081-1084.	0.5	5
179	Si/SiGe Thermoelectric Generators. ECS Transactions, 2013, 50, 959-963.	0.5	1
180	Long Wavelength {greater than or equal to}1.9 Åm Germanium for Optoelectronics Using Process Induced Strain. ECS Transactions, 2013, 50, 779-782.	0.5	2

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181	(Invited) Germanium/Silicon Heterostructures for Terahertz Emission. <i>ECS Transactions</i> , 2013, 50, 763-771.	0.5	4
182	Si/SiGe Tunneling Static Random Access Memories. <i>ECS Transactions</i> , 2013, 50, 987-990.	0.5	2
183	Mid-infrared plasmonic antennas made of electron-doped epitaxial germanium-on-silicon. , 2013, , .		1
184	Direct Band-gap Electroluminescence from Strained n-Ge Light Emitting Diodes. <i>ECS Transactions</i> , 2013, 50, 305-308.	0.5	1
185	Ohmic contacts to n-type germanium with low specific contact resistivity. <i>Applied Physics Letters</i> , 2012, 100, .	3.3	83
186	Scaling resonant tunnelling diodes and nanowires using SPICE modelling to optimise nanoscale performance. , 2012, , .		0
187	Nanofabrication of high aspect ratio ($\sqrt[4]{450}:1$) sub-10nm silicon nanowires using inductively coupled plasma etching. <i>Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics</i> , 2012, 30, .	1.2	73
188	Direct band-gap electroluminescence from strained n-doped germanium diodes. , 2012, , .		0
189	1.55 nm electroluminescence from strained n-Ge quantum wells on silicon substrates. , 2012, , .		0
190	Tuning the electroluminescence of n-Ge LEDs using process induced strain. , 2012, , .		0
191	1.55 nm direct bandgap electroluminescence from strained n-Ge quantum wells grown on Si substrates. <i>Applied Physics Letters</i> , 2012, 101, .	3.3	19
192	Si/SiGe nanoscale engineered thermoelectric materials for energy harvesting. , 2012, , .		0
193	Silicon nanowire devices with widths below 5 nm. , 2012, , .		0
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195	Process-Induced Strain Bandgap Reduction in Germanium Nanostructures. , 2012, , .		1
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